

TUNABLE SEMICONDUCTOR LASER AND PRODUCTION METHOD

5 Background of the Invention:

Field of the Invention:

The present invention relates to a tunable semiconductor laser having an active layer structure that is subdivided into at least two sections.

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U.S. Patent No. 4,896,325 describes a tunable semiconductor laser with a subdivision of the resonator structure into a plurality of sections. Mirrors at the resonator end faces are formed with a plurality of elements in the manner of a Fabry-  
15 Perot interferometer and can be set to different reflection maxima by application of suitable voltages. A further section of the resonator that is provided for achieving a high laser gain and a further section that is provided as a phase shifter are likewise driven by suitable voltages.

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U.S. Patent No. 5,365,541 describes the use of a photonic crystal as a resonator end mirror of a laser. The function of the photonic crystals is also explained in more detail in column 5 of this document. In accordance with the formation  
25 of valence and conduction bands in solids with a lattice-like periodic configuration of the atoms, periodically varying

regions of alternating refractive index are present in photonic crystals. As a result, for the radiation propagating in the photonic crystal, by analogy with the solid state, band gaps in the wavelength are produced in which wave-guiding is not possible. Such photonic crystals can therefore be used as mirrors for the relevant wavelength ranges.

U.S. Patent No. 5,684,817 describes a semiconductor laser in which regions of photonic crystals that form respective resonator end mirrors of an active laser structure are integrated in the component.

International Patent Disclosure WO 94/16345 describes an integrated optoelectronic component in which wave guidance is brought about by photonic crystals. The photonic crystals are integrated into the component by filling cylindrical regions with dielectric material.

U.S. Patent No. 6,141,370 describes a binary superimposed grating (BSG), in which regions of identical length and in each case one of two possible values of the refractive index are present. The regions alternate in a periodic sequence, a likewise periodic phase shift being superimposed. Attention is drawn to applications of such BSGs in tunable semiconductor lasers.

Summary of the Invention:

It is accordingly an object of the invention to provide a tunable semiconductor laser and a production method that overcome the above-mentioned disadvantages of the prior art devices and methods of this general type, that can be produced more simply.

With the foregoing and other objects in view there is provided, in accordance with the invention, a tunable semiconductor laser. The tunable semiconductor laser contains a resonator structure being subdivided longitudinally into at least two sections. The resonator structure has longitudinal ends, an active layer generating radiation, and resonator end mirrors and/or gratings for bringing about an occurrence of an envisaged number of discrete modes in the sections. The discrete modes have spacings from one another and differ in the two sections of the resonator structure. A device for providing separate current injection into the active layer is provided in at least two of the sections. Photonic crystals are disposed at least at the longitudinal ends of the resonator structure. The photonic crystals have, as a band gap in which no wave-guiding takes place, a wavelength range in which a principal wavelength of the tunable semiconductor laser lies or a maximum gain of the tunable semiconductor laser occurs.

The semiconductor laser has an active layer in a resonator structure with a longitudinal direction that is provided for wave-guiding and mode selection. A transverse wave guidance is preferably effected by index guidance in a separate  
5 confinement heterostructure (SCH), and a lateral wave guidance is preferably effected by a rib waveguide, which is known per se. The resonator structure contains resonator end mirrors at the longitudinal ends and/or at least one grating, thereby achieving the occurrence of an envisaged number of discrete  
10 modes.

The resonator structure is subdivided into at least two sections provided with contacts disposed at the component, for current injection, preferably into each section separately.  
15 By virtue of different dimensions in the longitudinal direction or by virtue of the formation of the grating structures disposed thereon, these sections are formed in such a way that the spacings of the modes that respectively occur therein in the sections are different from one another.

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Boundaries formed of photonic crystals are disposed at least at the outer longitudinal ends of the resonator structure, preferably at all the longitudinal ends of the sections. The wavelength range of the band gap of the photonic crystals  
25 contains a range of maximum gain of the laser or contains a principal wavelength of the laser; the principal laser

wavelength preferably lies about in the center of the band gap of the photonic crystals. The deviation of the mode spacings in the sections may be produced by the different length of the sections between the respective boundaries by photonic  
5 crystals or by grating structures. BSGs are preferably used as the gratings.

In accordance with an added feature of the invention, the spacings of the discrete modes differ in at least two of the  
10 sections of the resonator structure at least by about a half-value width of the discrete modes.

In accordance with a further feature of the invention, the two sections are two of a plurality of the sections having  
15 different mode spacings.

In accordance with an additional feature of the invention, the sections of the resonator structure have different longitudinal dimensions.  
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In accordance with another feature of the invention, at least one of the sections of the resonator structure is provided with a grating provided for mode selection. Preferably, the grating is a binary superimposed grating.  
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In accordance with another further feature of the invention, the spacings are in a range of 3 nm to 10 nm.

With the foregoing and other objects in view there is further  
5 provided, in accordance with the invention, a method for  
producing a semiconductor laser. The method includes growing  
and doping a semiconductor layer structure having confinement  
layers and at least one active layer for generating radiation  
disposed between the confinement layers, etching partial webs  
10 into the semiconductor layer structure using a mask, applying  
and patterning an additional further mask layer using a  
photoresist mask in accordance with photonic crystals to be  
produced and resulting in a patterned mask layer, etching  
holes into the semiconductor layer structure using the  
15 patterned mask layer, removing the patterned mask layer, and  
applying a further mask which leaves free regions provided for  
gratings to be produced. A metal layer is deposited and  
patterned to form at least one grating in the free regions. A  
dielectric material is applied for filling the holes provided  
20 for the photonic crystals. Contacts are applied to the  
semiconductor layer structure.

Other features which are considered as characteristic for the  
invention are set forth in the appended claims.

Although the invention is illustrated and described herein as embodied in a tunable semiconductor laser and a production method, it is nevertheless not intended to be limited to the details shown, since various modifications and structural  
5 changes may be made therein without departing from the spirit of the invention and within the scope and range of equivalents of the claims.

The construction and method of operation of the invention,  
10 however, together with additional objects and advantages thereof will be best understood from the following description of specific embodiments when read in connection with the accompanying drawings.

15 Brief Description of the Drawings:

Fig. 1 is a diagrammatic, longitudinal sectional view of a tunable semiconductor laser with gratings according to the invention;

20 Fig. 2 is a cross-sectional view of the semiconductor laser taken along the line II-II shown in Fig. 1;

Fig. 3 is a cross-sectional view of the semiconductor laser taken along the line III-III shown in Fig. 1;

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Fig. 4 is a diagrammatic, plan view of a resonator structure of the semiconductor laser of Fig. 1; and

Fig. 5 is a diagrammatic, plan view of the resonator structure of a further exemplary embodiment.

Description of the Preferred Embodiments:

Referring now to the figures of the drawing in detail and first, particularly, to Fig. 1 thereof, there is shown a first exemplary embodiment in a longitudinal section, that is to say in a cross section of the component in the longitudinal direction of a resonator structure. The layer structure may be grown on a substrate 1 e.g. by molecular beam epitaxy in a material system of InGaAsP. The resonator structure is subdivided into at least two sections each having a length of 400  $\mu\text{m}$  for example. The number of the sections is not defined. Three sections 1a, 1b, 1c are depicted in the exemplary embodiment illustrated in Figs. 1 to 4.

Confinement layers 3 for transverse wave guidance are situated above and below an active layer 2 provided for generating radiation. It is also possible to provide separate layers for optical and electrical confinement. The layers above and below the active layer 2 are doped, for the purpose of current injection, and for electrical conduction of mutually opposite conductivity types. A cladding layer or covering layer 4 made



of a semiconductor material is patterned into a web on the top side which is interrupted in the longitudinal direction, thereby forming partial webs 5a, 5b, 5c assigned to the sections 1a, 1b, 1c.

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Photonic crystals 6 are provided as the resonator end mirrors and as boundaries for the partial resonator structures in accordance with the sections 1a, 1b, 1c. It suffices if the photonic crystals 6 are bounded to the layer position of the active layer 2 in the transverse direction; however, the photonic crystals 6 are preferably produced only after the growth of all the semiconductor layers and then encompass, as depicted, the confinement layers 3 and the covering layer 4 as well.

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Contacts 7a, 7b, 7c for separate current injection into at least two of the sections 1a, 1b are situated on the topside of the partial webs 5a, 5b, so that the laser can be operated and tuned. A further contact 8 is situated on the underside of the substrate 1. Instead of this, the contact 8 may be disposed on the topside of the component laterally with respect to the strip-type resonator structure and be electrically conductively connected to the underside of the active layer 2 via doped regions formed in the semiconductor material.

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Gratings 9a, 9b provided in the exemplary embodiment are preferably disposed laterally with respect to the partial webs 5a, 5b and may be produced as BSGs by electron beam lithography. The gratings 9a, 9b are preferably just as long  
5 as the associated sections 1a, 1b of the resonator structure. The gratings 9a, 9b are configured e.g. in such a way that a predetermined number of reflection maxima, for example ten, are formed in each section 1a, 1b, a central mode lying in the region of the gain maximum of the semiconductor material of  
10 the active layer 2 and mode spacings being chosen in relation to the number of modes such that monomode nature is achieved. Furthermore, the spacings of the modes in the sections must differ at least by about the half-value width of the modes, that is to say the reflection peaks.

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In a preferred exemplary embodiment with in each case about ten modes, that is the case with mode spacings in the range of 3 nm to 10 nm, typically about 5 nm, which differ in the two sections preferably by about 7 to 10%. The tuning may be  
20 performed through suitable variation of the currents injected into the sections, both (quasi) continuously and with inclusion of mode jumps. A plurality of sections with different mode spacings may also be present.

25 The reflector end mirror is formed with the best possible reflection, that is to say with a reflection factor of close

to 1, by the photonic crystals 6 being disposed there in highly reflective fashion. The other reflector end mirror provided for radiation emergence may be split for the purpose of coupling out light, which is known per se. The topside of the component may be leveled with a planarization layer 10, e.g. made of BCB. The contours of the partial webs 5a, 5b, 5c are therefore depicted by broken lines as contours concealed by the planarization layer 10 in Fig. 1. The laser is tuned through suitable variations of the currents injected into the sections.

Fig. 2 shows the cross section through the partial web 5a that is specified by a dash-dotted line in Fig. 1. The reference symbols correspond to those of Fig. 1 and need not be explained separately. Fig. 2 reveals, in particular, that the gratings 9a are disposed laterally with respect to the web. No photonic crystals 6 need be present in this region of the laser. The position of the cross section of Fig. 1 is indicated by the dash-dotted line in Fig. 2.

Fig. 3 illustrates a cross section that is coplanar with respect to the cross section in accordance with Fig. 2 in the region between two partial webs 5b, 5c whose position is likewise marked in Fig. 1. In this example, the photonic crystals 6 are also present in the lateral regions - with respect to the web - between the partial webs. The nearest

partial web 5c in the viewing direction is depicted for orientation purposes, to be precise by broken lines as a contour concealed by the planarization layer 10.

5 The plan view of Fig. 4 reveals the sections 1a, 1b, 1c with the contacts 7a, 7b, 7c, which in each case completely cover the top sides of the partial webs 5a, 5b, 5c in this example. The structure of the gratings 9a, 9b and of the photonic crystals 6 is depicted diagrammatically. It can be seen that  
10 the photonic crystals 6 usually form a hexagonal grid. The break line depicted on the right may be followed by further integrated electronic or optoelectronic components. The third partial web 5c may be configured in bent fashion toward a coupling-out region for the purpose of better coupling-out of  
15 light. The third partial web 5c may also be provided as an amplifier, for example, which is operated by the contacts 7c and 8.

Not all the sections need be provided with a respective  
20 grating. The resonator structure may have two or more sections that are different from one another in each case by virtue of the length and/or grating structures provided.

The structure illustrated in Figs. 1 to 4 may be produced by a  
25 procedure in which first the semiconductor layers are grown over the whole area and are doped in the envisaged manner.

The partial webs are etched using a mask. A mask layer, preferably an  $\text{SiO}_2$  layer, is applied and patterned with a photoresist mask in accordance with the photonic crystals to be produced. The photoresist is removed. At the regular intervals provided for the photonic crystals 6, holes are etched into the semiconductor material, preferably right into the lower confinement layer 3, using the patterned mask layer. The material of the mask layer is removed.

Using a further photoresist mask, which leaves free the regions provided for the coatings, a metal layer is deposited and patterned, thereby producing, in particular, a respective BSG. After the removal of the photoresist, a dielectric material, preferably BCB, is applied by which the holes provided for the photonic crystals are filled and the topside is planarized. Finally, the contacts are applied.

A further exemplary embodiment dispenses with the gratings, so that the resonator structure is formed solely by the reflective boundaries of the photonic crystals 6. Fig. 5 illustrates a diagrammatic plan view of such a resonator structure in which the sections 1a, 1b, 1c are formed. The sections 1a, 1b, 1c are bounded laterally and longitudinally by photonic crystals 6 which bring about not only the longitudinal section but also the lateral wave guidance.

The lengths of the sections 1a, 1b, 1c are chosen to be different, so that the mode spacings in the sections are different, preferably at least by about the half-value width of the modes, that is to say the reflection peaks. On account  
5 of the amplifying property of the semiconductor material of the active layer, it is possible to set an envisaged number of modes. In order to achieve monomode nature the mode spacings and the numbers of modes are coordinated with one another. In this exemplary embodiment, too, the mode spacings in the  
10 sections may differ by about 7 to 10% and are typically in the range of 3 nm to 10 nm.

In the exemplary embodiment, coarse tuning of the laser is effected through a suitable variation of the currents injected  
15 into the sections; fine tuning is possible by varying the temperature. In this example, a coupling-out region 11 is situated at an end of the resonator structure at which the boundary by photonic crystals 6 is sufficiently thin to enable light emergence. In this exemplary embodiment, too, further  
20 integrated electronic or optoelectronic components may be present. The last section 1c of the resonator structure that is provided for the purpose of coupling out light can in this case likewise be led in bent fashion to the edge of the component. The number of sections is not defined; two  
25 sections in which the mode spacings differ in the envisaged manner suffice for the tunability of the laser.

Compared with previous configurations of tunable semiconductor lasers, the solution according to the invention affords the advantage that the photonic crystals 6 can be produced in a  
5 simple manner by standard lithography methods and the reflectivities and coupling intensities of the sections of the resonator structure can thus be set without a high outlay. The high index jumps that can be realized by the photonic crystals make it possible to produce novel resonator  
10 geometries that are not possible in the conventional art.